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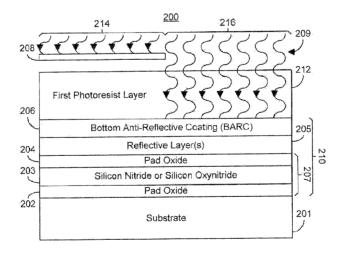
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(54) Title: METHOD AND SYSTEM FOR CREATING SELF-ALIGNED TWIN WELLS WITH CO-PLANAR SURFACES IN A SEMICONDUCTOR DEVICE



(57) Abstract: A method and system for providing a twin well in a semiconductor device is described. The method and system include providing at least one interference layer and providing a first mask that covers a first portion of the semiconductor device and uncovers a second portion of the semiconductor device. The first and second portions of the semiconductor device are adjacent. The method and system also include implanting a first well in the second portion of the semiconductor device after the first mask is provided. The method and system also include providing a second mask. The interference layer(s) are configured such that energy during a blanket exposure develops the second mask that uncovers the first portion and covers the second portion of the semiconductor device. The method and system also include implanting a second well in the first portion of the semiconductor device after the second mask is provided.





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B. FIELDS SEARCHED		
Minimum documentation searched (classification system followed by classification symbols) USPC - 438/527; 257/E21.474 IPC(8) - H01L 21/426 (2008.04)		
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Electronic data base consulted during the international search (name of data base and, where practicable, search terms used) PubWEST(USPT,PGPB,EPAB,JPAB); DialogPRO(Engineering); Google Scholar Search Terms: reflective layer on BARC, BARC layer, twin well and reflective layer, pad oxide, twin wells, forming twin wells, silicon nitride		
C. DOCUMENTS CONSIDERED TO BE RELEVANT		
Category* Citation of document, with indication, where a	appropriate, of the relevant passages	Relevant to claim No.
X US 5,670,395 A (Pan) 23 September 1997 (23.09.1997) col. 2, ln 5-13, 14-16, 19-20, 33-40, 45-47	97), entire document especially abstract;	1, 6, 18 2-5, 7-17
Y US 6,723,649 B2 (Chang et al.) 20 April 2004 (20.04. 57-60; col. 3, In 50-55)	2004), entire document especially col. 2, In	2-5, 7-16
Y US 6,297,170 B1 (Gabriel et al.) 02 October 2001 (02	US 6,297,170 B1 (Gabriel et al.) 02 October 2001 (02.10.2001), entire document especially col. 1, In 52-57; col. 2, In 5-15; col. 4, In 53-60	
	US 5,393,692 A (Wu) 28 February 1995 (28.02.1995), entire document especially abstract	
Y US 4,881,236 A (Brueck et al.) 14 November 1989 (1 2, ln 10-15	US 4,881,236 A (Brueck et al.) 14 November 1989 (14.11.1989), entire document especially col. 2, In 10-15	
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